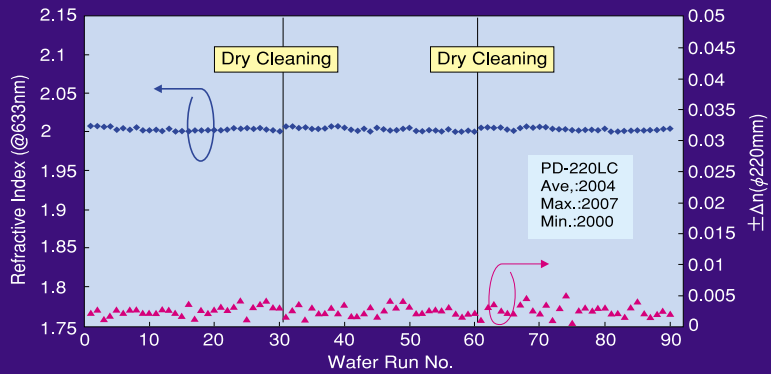


Properties of SiN film deposited with PD-220LC

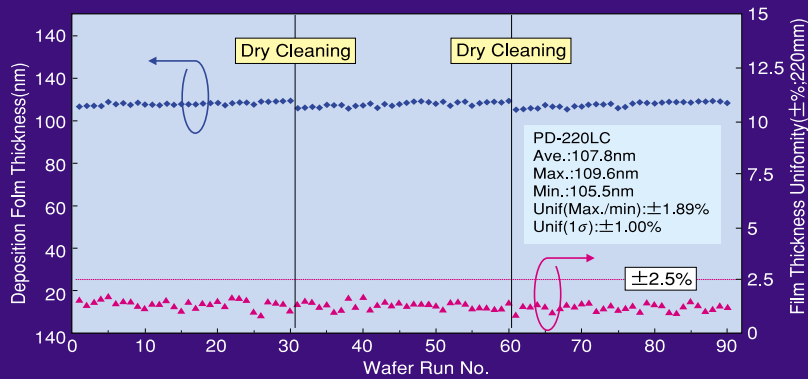
Repeatability of SiN Deposition



Refractive index uniformity



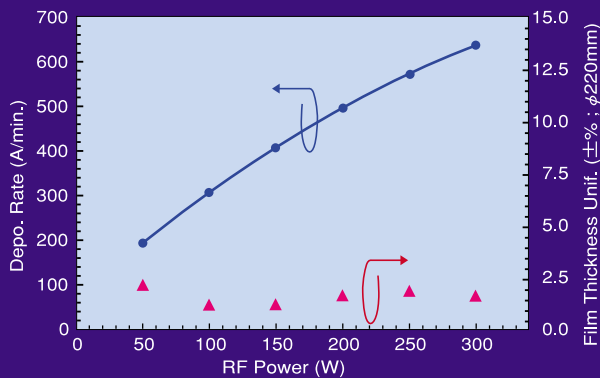
Thickness uniformity



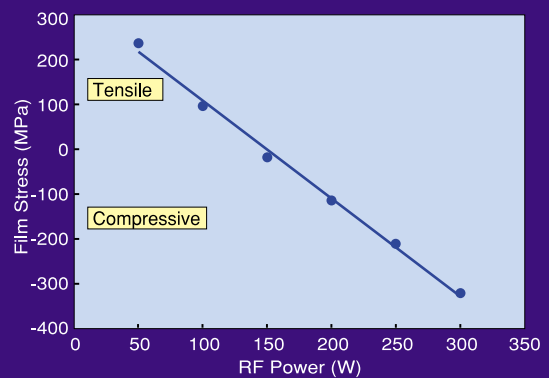
Stable repeatability of the SiN deposition

Controllability of SiN Deposition

Deposition rate & film thickness uniformity



Stress



Wide process window and wide control range is achieved.

